



INDIAN INSTITUTE OF TECHNOLOGY GUWAHATI
SHORT ABSTRACT OF THESIS

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Programme of Study : Ph.D.

Thesis Title: **Investigations on selected cobalt-based quaternary Heusler alloys for spintronic applications**

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Thesis Submitted to the : Department of Physics
Academic Division

Date of completion of Thesis Viva-
Voce Exam : 17.12.2025

Key words for description of Thesis Work : Heusler alloys, Magnetic materials, Half-metallicity, Magnetoresistance, and Spintronics

SHORT ABSTRACT

Systematic experimental and theoretical investigations have been conducted to explore the structural, magnetic, and electronic properties of bulk $\text{Co}_{2-x}\text{MnV}_x\text{Al}$ ($x = 0.0, 0.25, \text{ and } 0.5$) and $\text{Co}_{2-x}\text{FeTi}_x\text{Al}$ ($x = 0.00, 0.25, 0.50, 0.75, \text{ and } 1.00$) Heusler alloys. These investigations explored the impact of V and Ti substitution for Co in $\text{Co}_{2-x}\text{MnV}_x\text{Al}$ and $\text{Co}_{2-x}\text{FeTi}_x\text{Al}$ Heusler alloys, respectively. These studies demonstrated a viable approach to attain 100% spin polarization (P) by tuning the minority spin bandgap at Fermi level (E_F) while retaining the ferromagnetic character. After achieving high P , the next step was to comprehend impact of P on Gilbert damping constant (α) to ascertain the efficiency of the free ferromagnetic layer in magnetoresistance devices. In this regard, off-stoichiometric compositions of the promising $\text{Co}_2\text{FeGa}_{0.5}\text{Ge}_{0.5}$ Heusler alloy was considered. Off-stoichiometric $\text{Co}_{1.77}\text{Fe}_{1.23}\text{Ga}_{0.56}\text{Ge}_{0.44}$ Heusler alloy thin film was heat treated at different annealing temperature (T_{an}) to improve its atomic ordering. Effect of improvement in atomic ordering on intrinsic contribution to α and its correlation with P was then analysed. This investigation revealed remarkably low α in the $\text{Co}_{1.77}\text{Fe}_{1.23}\text{Ga}_{0.56}\text{Ge}_{0.44}$ film annealed at $T_{\text{an}} = 600$ °C. It also clarified that atomic disorder significantly influences α , and α decreases with increasing P resulting from improved atomic ordering. To assess the potential of the spin-orbit torque mechanism for achieving energy-efficient switching of the magnetization in the free ferromagnetic layer, spin mixing conductance ($g_{\text{eff}}^{\uparrow\downarrow}$) across the interface of $\text{Co}_{2.06}\text{Fe}_{0.99}\text{Ga}_{0.53}\text{Ge}_{0.42}/\text{Pt}$ bilayers was evaluated. Furthermore, a detailed investigation was carried out to assess the effect of ultrathin Cu, Ni, Ru, Ta, and Cr insertion layers on $g_{\text{eff}}^{\uparrow\downarrow}$ of $\text{Co}_{2.06}\text{Fe}_{0.99}\text{Ga}_{0.53}\text{Ge}_{0.42}/\text{Pt}$ bilayer film after ensuring that there are no insertion-layer-induced changes in the atomic structure of the Pt layer.